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INFORMATION DISCLOSURE STATEMENT BY APPLICANT

(Use several sheets if necessary)

Atty. Docket No.
1789-10000Serial No.
10/090,211Applicant
James M. Tour et al.Filing Date
March 4, 2002Group
2816 1742

REFERENCE DESIGNATION U.S. PATENT DOCUMENTS

EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUB- CLASS	FILING DATE IF APPROPRIATE
WL	AA	4,694,972	10/23/90	Sagiv et al.	204	418	
WL	AB	5,589,692	12/31/96	Reed	257	23	04/11/95
WL	AC	6,060,327	05/09/00	Keen	436	518	05/14/97
WL	AD	6,090,933	07/18/00	Kayyem et al.	536	253	08/14/97
WL	AE	6,259,277	07/10/01	Tour et al.	326	136	06/26/99
WL	AF	6,272,038	08/07/01	Clausen et al.	365	151	01/14/00

FOREIGN PATENT DOCUMENTS

		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUB- CLASS	Translation	
							YES	NO

OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)

WL	AG	F. Ma et al; Potential-Assisted Deposition of Alkanethiols on Au: Controlled Preparation of Single- and Mixed-Component SAMs; Langmuir 2000, 16 (pp. 6188-6190)						
WL	AH	PCT International Search Report for International Application No. PCT/US02/06509, dated 12 August 2002 (5 pg.)						

EXAMINER

William Leader

DATE CONSIDERED

3/10/2005

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP '609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to the applicant.